

Title (en)
FAÇADE CONSTRUCTION

Title (de)
FASSADENKONSTRUKTION

Title (fr)
CONSTRUCTION DE FAÇADE

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Abstract (en)
[origin: WO2015164987A1] The invention relates to a facade construction (11) comprising first thermal barrier elements (13) which are arranged on a supporting framework (19), in particular of an outer wall of a building, second thermal barrier elements (15) which are arranged on the first thermal barrier elements (13) and a retaining device (17) which is arranged on the supporting framework (19) and holds the first and second thermal barrier elements (13, 15) on the supporting framework (19). The facade device further comprises an intermediate layer in the form of a multiplicity of mounting plates (49), which intermediate layer is attached to and supported by the retaining device (17), wherein the second thermal barrier elements (15) are arranged on the intermediate layer.

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